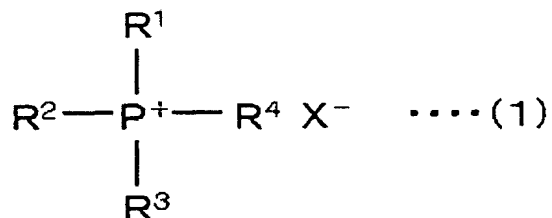


AMENDMENTS TO THE CLAIMS

Please amend the claims as follows.

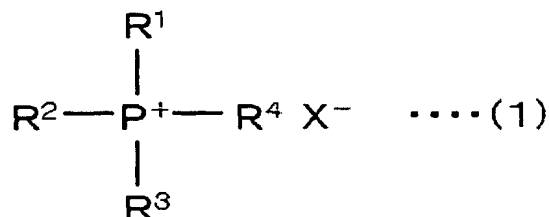
1. (Original) An antistatic agent for resins, containing phosphonium salts represented by the general formula (1):



(wherein R¹, R², and R³ are each a straight-chain or branched alkyl group having 3 to 8 carbon atoms, and R⁴ is a straight-chain or branched alkyl group having 10 to 22 carbon atoms; each alkyl group may have substituted hydroxy group or alkoxy group; R¹, R², and R³ may be the same or different from each another; and X⁻ is a tetrafluoroborate ion or a hexafluorophosphate ion).

2. (Original) The antistatic agent for resins according to Claim 1, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium tetrafluoroborate.
3. (Original) The antistatic agent for resins according to Claim 1, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium hexafluorophosphate.
4. (Currently Amended) The antistatic agent for resins according to ~~any of Claims 1 to 3~~ Claim 1, wherein the residual halogen is 500 ppm or less.
5. (Currently Amended) The antistatic agent for resins according to ~~any of Claims 1 to 3~~ Claim 1, wherein the antistatic agent is for thermoplastic resins.
6. (Original) The antistatic agent for resins according to Claim 5, wherein the antistatic agent is for polyamide resins or for polyester resins.
7. (Curently Amended) The antistatic agent for resins according to ~~any of Claims 1 to 4~~ Claim 1, wherein the antistatic agent is for thermoset resins.

8. (Original) The antistatic agent for resins according to Claim 7, wherein the antistatic agent is for polyurethane resins or for epoxy resins.
9. (Original) An antistatic resin composition, containing a resin and phosphonium salts represented by the general formula (1):



(wherein R¹, R², and R³ are each a straight-chain or branched alkyl group having 3 to 8 carbon atoms, and R⁴ is a straight-chain or branched alkyl group having 10 to 22 carbon atoms; each alkyl group may have substituted hydroxy group or alkoxy group; R¹, R², and R³ may be the same or different from each another; and X⁻ is a tetrafluoroborate ion or a hexafluorophosphate ion).

10. (Original) The antistatic resin composition according to Claim 9, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium tetrafluoroborate.
11. (Original) The antistatic resin composition according to Claim 9, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium hexafluorophosphate.
12. (Currently Amended) The antistatic resin composition according to ~~any of Claims 9 to 11~~ Claim 9, wherein the amount of the phosphonium salt compounded is 0.01 to 50 weight parts per 100 weight parts resin.
13. (Currently Amended) The antistatic resin composition according to ~~any of Claims 9 to 11~~ Claim 9, wherein the resin is a thermoplastic resin.
14. (Original) The antistatic resin composition according to Claim 13, wherein the thermoplastic resin is a polyamide or a polyester.
15. (Currently Amended) The antistatic resin composition according to ~~any of Claims 9 to 11~~ Claim 9, wherein the resin is a thermoset resin.

16. (Original) The antistatic resin composition according to Claim 15, wherein the thermoset resin is polyurethane resin or epoxy resin.
17. (Currently Amended) The antistatic resin composition according to ~~any of Claims 9 to 16~~Claim 9, wherein carbon material is further contained.
18. (Original) The antistatic resin composition according to Claim 17, wherein the carbon nanotubes are contained as the carbon material.
19. (Currently Amended) An antistatic resin molded product, wherein the antistatic resin composition of ~~any of Claims 9 to 18~~Claim 9 is molded.